



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

: Confirmation No. 9938

Hiroshi TAKANASHI et al.

: Docket No. 2001_0476

Serial No. 09/838,118

: Group Art Unit 1752

Filed April 20, 2001

: Examiner S. Lee

NEGATIVE-WORKING PHOTORESISTIVE
RESIN COMPOSITION AND PHOTORESISTIVE
RESIN PLATE USING THE SAME

RECEIVED
SEP 25 2003
TC 1700
[Handwritten signature]

PETITION FOR EXTENSION OF TIME

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Petition hereby is made for a three month extension of time to respond to the communication of March 20, 2003.

The fee of \$930.00 is

submitted herewith.

to be charged to Deposit Account No. 23-0975. A duplicate copy of this Petition is enclosed.

Small entity status of this application is established by a Small Entity Status Assertion which

is enclosed.

has been previously submitted.

Respectfully submitted,

Hiroshi TAKANASHI et al.

09/24/2003 AWONDAF1 00000037 09838118

02 FC:1253

930.00 0P

By Matthew Jacob
Matthew Jacob
Registration No. 25,154
Attorney for Applicants

MJ/da

Washington, D.C. 20006-1021

Telephone (202) 721-8200

Facsimile (202) 721-8250

September 22, 2003